

**AMENDMENTS TO THE CLAIMS:**

Kindly add new claims 15-17 as follows. A detailed listing of all claims is as follows.

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1. (Previously Amended) A liquid crystal display device comprising:  
an insulating film on a first substrate;  
a first electrode having a plurality of slit patterns directly contacting the insulating film;  
at least one light-shielding layer below each slit pattern;  
a second electrode on a second substrate; and  
a liquid crystal layer between the first and second substrates, the liquid crystal layer  
having different alignment directions by each slit pattern.

2. (Original) The device as claimed in claim 1, wherein the light-shielding layer is  
located below a middle portion of the first electrode.

3. (Canceled)

4. (Previously Amended) A liquid crystal display device comprising:  
an insulating film on a first substrate;  
a first electrode having a plurality of slit patterns directly contacting the insulating film;  
at least one light-shielding layer below the first electrode and the slit patterns;  
a second electrode on a second substrate; and  
a liquid crystal layer between the first and second substrates, the liquid crystal layer  
having different alignment directions by each slit pattern.

5. (Original) The device as claimed in claim 1, wherein the first electrode includes a transparent conductive material.

6. (Original) The device as claimed in claim 1, wherein the second electrode includes a transparent conductive material.

7. (Original) The device as claimed in claim 1, further comprising an insulating film on an entire surface of the first substrate.

8. (Previously Amended) A method of fabricating a liquid crystal display device on first and second substrates, comprising:

forming at least one light-shielding layer on the first substrate;

forming an insulating layer on the entire surface of the first substrate and on the at least one light-shielding layer;

forming a first electrode directly on the insulating layer, the first electrode having a plurality of slit patterns over the light-shielding layer;

forming a second electrode on the second substrate;

assembling the first and second substrates; and

forming a liquid crystal layer having different alignment directions by each slit pattern between the first and second substrates.

9. (Original) The method as claimed in claim 8, wherein the light-shielding layer is formed below a middle portion of the first electrode.

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10. (Original) The method as claimed in claim 8, wherein the light-shielding layer is formed below each slit pattern.

11. (Original) The method as claimed in claim 8, wherein the light-shielding layer is formed below middle portions of both the first electrode and the slit patterns.

12. (Original) The method as claimed in claim 8, wherein the first electrode includes a transparent conductive material.

13. (Original) The method as claimed in claim 8, wherein the second electrode includes a transparent conductive material.

14. (Original) The method as claimed in claim 8, further comprising forming an insulating film on an entire surface of the first substrate and the light-shielding layer.

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15. (New) The device as claimed in claim 1, wherein both the first electrode and the light-shielding layer are within a same unit pixel region. (gate bus)

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16. (New) The device as claimed in claim 4, wherein both the first electrode and the light-shielding layer are within a same unit pixel region.

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17. (New) The method as claimed in claim 8, wherein both the first electrode and the light-shielding layer are within a same unit pixel region.

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